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Company:	US Patent Office	Date:	November 29, 2005
Fax:	(571) 273-8300	Pages:	4 (including cover sheet)
Your Re:	10/622,955	Our Re:	ML1021US

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:	Justin K. Brask et al.	§	Art Unit:	2811
Serial No.:	10/622,955	§	Examiner:	Sara W. Crane
Filed:	July 18, 2003	§	Atty Docket:	ITL.1021US P16708
For:	Etching Metal Silicides and Germanides	§	Assignee:	Intel Corporation

Mail Stop AF
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REPLY TO FINAL REJECTION

Sir:

In response to the final rejection mailed October 18, 2005, please amend the above-referenced patent application as follows:

Date of Deposit: November 29, 2005
I hereby certify that this correspondence is being facsimile
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